



#8 reconsideration  
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tr

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re U.S. Patent Application )

Applicant: Chikayoshi Kamata )

Serial No. 09/748,919 )

Filed: December 27, 2000 )

For: GIANT MAGNETO- )  
RESISTIVE DEVICE AND )  
A FABRICATION PROCESS )  
THEREOF )

Art Unit: 2652 )

Examiner: Nguyen, D. )

I hereby certify that this paper is being deposited with the  
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1 Oct 02

Date

F-CLASS. WCM

Appr. February 20, 1998

Registration No. 29367

Attorney for Applicant

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Technology Center 2600

AMENDMENT A

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

In response to the office action mailed June 19, 2002, please consider the  
following remarks.

REMARKS

Claim 1 stands rejected under § 102 on the basis of Chen et al. Applicant  
respectfully traverses this rejection for the following reasons.

It is the object of the present invention to provide an overlay type MR sensor  
with minimized oxidation of the cap layer covering the MR structure, by providing an